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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Yen et al.

Serial No.: 10/720,735

Filed: November 24, 2003

For: **Rework Process of Patterned
Photo-Resist Layer**

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) Group Art Unit: 2813
)
) Examiner: Mitchell, James M.
)
) Confirmation No.: 2750
)
) TKHR Docket: 251310-1100
)
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Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Mail Stop Amendment; Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450, on June 27, 2005.


Signature - Hui Chin Barnhill

RESPONSE TO RESTRICTION/ELECTIONS REQUIREMENTS

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed June 1, 2005 has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.